



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: **Koji NOZAKI et al.**

Group Art Unit: **1752**

Application Number: **10/623,679**

Examiner: **Amanda C. Walke**

Filed: **July 22, 2003**

Confirmation Number: **5083**

For: **RESIST PATTERN THICKENING MATERIAL, RESIST PATTERN
AND PROCESS FOR FORMING THE SAME, AND
SEMICONDUCTOR DEVICE AND PROCESS FOR
MANUFACTURING THE SAME**

Attorney Docket Number: **030891**
Customer Number: **38834**

PETITION FOR EXTENSION OF TIME

Commissioner for Patents
P. O. Box 1450
Alexandria, VA 22313-1450

July 6, 2007

Sir:

Applicants petition the Commissioner for Patents to extend the time for response to the Office Action dated February 8, 2007 for two months from May 8, 2007 to July 8, 2007.

Attached please find a check in the amount of **\$630.00** to cover the cost of the extension (\$450.00) and the Information Disclosure Statement (\$180.00). If any additional fees are due in connection with this paper, please charge Deposit Account No. 50-2866.

Respectfully submitted,

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Enclosure: Check of \$630.00